

Docket No.: 57454-984

**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of	:	Customer Number: 20277
	:	
Hiroyasu NOHSOH, et al.	:	Confirmation Number:
	:	
Serial No.: Divisional of Appl. No. 09/845,291	:	Group Art Unit:
	:	
Filed: December 03, 2003	:	Examiner:
	:	
For: SEMICONDUCTOR DEVICE AND PROCESS FOR SAME		

**INFORMATION DISCLOSURE STATEMENT**

Mail Stop Patent Application  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached form PTO-1449. It is respectfully requested that the references be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

The references were cited by or submitted to the U.S. Patent and Trademark Office in parent application Serial No. 09/845,291, filed May 1, 2001, which is relied upon for an earlier

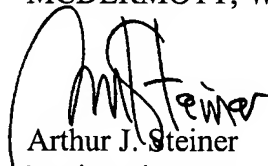
**Serial No.:** Divisional of Appl. No.

filing date under 35 USC 120. Thus, copies of these references are not attached. 37 CFR 1.98(d).

Please charge any shortage in fees due in connection with the filing of this paper, including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

MCDERMOTT, WILL & EMERY

A handwritten signature in black ink, appearing to read 'Arthur J. Steiner', is written over a circular stamp.

Arthur J. Steiner  
Registration No. 26,106

600 13<sup>th</sup> Street, N.W.  
Washington, DC 20005-3096  
(202) 756-8000 AJS:prg  
Facsimile: (202) 756-8087  
**Date: December 3, 2003**

<b>INFORMATION DISCLOSURE CITATION IN AN APPLICATION</b>  (PTO-1449)				ATTY. DOCKET NO. <b>57454-984</b>		SERIAL NO. <b>Divisional f Appl. N . 09/845,291</b>	
				APPLICANT <b>Hiroyasu NOHSOH, et al.</b>			
				FILING DATE <b>December 03, 2003</b>		GROUP	
<b>U.S. PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code <sup>2</sup> (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
		US 6,258,647 B1	07/10/2001	Lee et al.			
		US 6,030,861	02/29/2000	Liu			
		US 5,550,079	08/27/1996	Lin			
		US 5,468,669	11/21/1995	Lee et al.			
		US 6,214,656 B1	04/10/2001	Liaw			
		US 5,633,523	05/1997	Kato			
		US 6,333,527 B2	12/2001	Kim			
		US 5,882,965	03/1999	Schwalke et al.			
		US 5,625,183	04/1997	Kashitani et al.			
		US 6,174,775 B1	01/2001	Liaw			
		US 6,413,803 B1	07/2002	Liaw			
		US					
		US					
		US					
<b>FOREIGN PATENT DOCUMENTS</b>							
EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Codes - Number - Kind Codes (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Figures Appear	Translation	
						Yes	No
		JP 9-289257	11/04/1997	SONY CORP.			
		JP 6-104259	04/15/1994	NEC CORP.			
		JP 10-50857 A	02/20/1998	SONY CORP.			
<b>OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)</b>							
EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.					
		S. WOLF, Ph.D., "Silicon Processing for the VLSI Era", Vol. 2: Process Integration, Lattice Press, 1990, pages 45-58.					
EXAMINER				DATE CONSIDERED			

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.